Claims

1. A method for improving the heat stability of polyparaxylylene and a derivative film thereof wherein when the polyparaxylylene or the derivative film thereof represented by a below-described general formula 1 is formed by a chemical vapor deposition method, an amino-(2.2)-paracyclophane compound represented by a below-described general formula 3 is mixed in a (2.2)-paracyclophane compound represented by a below-described general formula 2 to form a film.

General formula 1

$$\begin{array}{c|c}
X_1 \\
CH_2 \\
X_2
\end{array}$$

(In the formula 1, X_1 and X_2 designate hydrogen, lower alkyl or halogen. X_1 and X_2 may be the same or different. n represents a degree of polymerization.)

General formula 2

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(In the formula 2, X_1 and X_2 have the same meanings as those of the formula 1.)

General formula 3

(In the formula 3, X_3 designates hydrogen or a lower alkyl group. Y_1 and Y_2 designate hydrogen or an amino group and both Y_1 and Y_2 are not hydrogens at the same time.)

2. The method for improving the heat stability of polyparaxylylene and a derivative film thereof according to claim 1, wherein the polyparaxylylene and the derivative film thereof is a film of polyparaxylylene (in the general formula 1, X_1

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and X_2 = hydrogen), polymonochloroparaxylylene (in the general formula 1, X_1 = hydrogen and X_2 = chlorine) or polydichloroparaxylylene (in the general formula 1, X_1 and X_2 = chlorine).

- The method for improving the heat stability of polyparaxylylene and a 3. film thereof according claim 1 2, derivative to or wherein the amino-(2.2)-paracyclophane compound is a monoamino-(2.2)-paracyclophane (in the general formula 3, Y_1 = hydrogen and Y_2 = amino group) or a diamino-(2.2)-paracyclophane (in the general formula 3, Y_1 and Y_2 = amino group).
- 4. A polyparaxylylene derivative represented by a below-described general formula 4.

General formula 4

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$$\begin{array}{c} \begin{array}{c} \begin{array}{c} X_1 \\ \\ CH_2 \end{array} \end{array} \end{array} \begin{array}{c} \begin{array}{c} X_3 \\ \\ Y_1 \end{array} \end{array} \begin{array}{c} CH_2 \end{array} \begin{array}{c} \\ \\ \\ CH_2 \end{array} \end{array} \begin{array}{c} \\ \\ CH_2 \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} CH_2 \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} CH_2 \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} CH_2 \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} CH_2 \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}$$

(In the formula 4, X_1 and X_2 designate hydrogen, lower alkyl or halogen. X_1 and X_2 may be the same or different. X_3 designates hydrogen or a lower alkyl group. Y_1 and Y_2 designate hydrogen or an amino group and both Y_1 and Y_2 are not hydrogens at the same time. n, m and p designate a degree of polymerization.)

5. The polyparaxylylene derivative according to claim 4, wherein a thin film is formed.